Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
SI	5282	((isolat\$3 oxide STI LOCOS ONO) near (layer film)) with SOI	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 14:58
S2	632	S1 and (pn near junction)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:04
S3	482	S2 and (metal silicide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:03
S4	260	S3 and (nitride near (film layer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 14:15
S5	22409	((isolat\$3 oxide STI LOCOS ONO) near (layer film)) near2 (nitride near (film layer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:04
S6	1181	S5 and (pn near junction)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:03
S7	978	S6 and (metal silicide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:05
S8	7152	(isolat\$3 oxide STI LOCOS) near (layer film) near (nitride near (film layer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:04

S9	352	S8 and (pn near junction)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:05
S10	269	S9 and (metal silicide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/11 15:05